Photochemical Reaction of Silyl-Substituted 1,4-Disila(Dewar-benzene) with Isocyanide and Phenylacetylene

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ABSTRACT: *The irradiation of silyl-substituted 1,4-disila(Dewar-benzene)* **1** *with light of wavelength* λ > *320 nm in the presence of 2,6-dimethylphenylisocyanide or phenylacetylene produced 1,4-bis(ditert-butylmethylsilyl)-2,3,5,6-tetraethyl-7-(2,6-dimethylphenylimino)-1,4-disilabicyclo[2.2.1]hepta-2,5 diene* **5** *or 1,4-bis(di-tert-butylmethylsilyl)-2,3,5,6 tetraethyl-1-(2-phenylethynyl)-1,4-disilacyclohexa-2,5 diene* **6***, respectively. The molecular structures of* **5** *and* **6** *were determined by spectroscopic data and X-ray crystallography.* © 2008 Wiley Periodicals, Inc. Heteroatom Chem 19:87–92, 2008; Published online in Wiley InterScience (www.interscience.wiley.com). DOI 10.1002/hc.20411

INTRODUCTION

Several silaaromatic compounds have recently been synthesized, and their unique structures, reactivity, and aromaticity have been extensively studied [1–3]. Very recently, we have succeeded in isolating a stable 1,2-disilabenzene derivative for the

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first time (see [3]). In contrast, 1,4-disilaaromatics have never been isolated as stable compounds, although there are some reports of the direct observation by UV–vis spectroscopy of the parent 1,4-disilabenzene in a frozen Ar matrix at 10 K [4] and of the chemical trapping of intermediate 1,4-disilabenzenes with MeOH or acetylene derivatives [5]. Moreover, Ando et al. have characterized 1,4-disila(Dewar-benzene) and 2,5-disilabenzvalene, that is, valence isomers of 1,4-disilabenzene, by isomerizations of bis(silacyclopropene) [6].

Despite its very interesting reactivity and the highly strained structure, the chemistry of 1,4disila(Dewar-benzene) derivatives is very limited because of synthetic difficulties. Quite recently, we have developed a new and simple synthetic method for silyl-substituted 1,4-disila(Dewar-benzene) (**1**), together with the unexpected insertion reaction of CO into the strained $Si-Si$ bond of 1, to form a stable cyclic disilyl ketone (**2**) and the photochemical isomerization of **1** to produce the corresponding 2,5-disilabenzvalene (**3**) [7]. In addition, we have reported the reduction of **1** with metallic lithium leading to the formation of the corresponding dianionic derivative (4^{2-}) , representing a nonaromatic 8π electron cyclic system (Scheme 1) [8]. As the extension of reactivity of 1,4-disila(Dewar-benzene) **1**, we describe here the unique photochemical reactivity of **1** in the presence of 2,6-dimethylphenylisocyanide and phenylacetylene.

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SCHEME 1

RESULTS AND DISCUSSION

Irradiation of a THF solution of 1,4-disila(Dewarbenzene) **1** with light of wavelength $\lambda > 320$ nm in the presence of an isocyanide 2.6 -Me₂C₆H₃NC resulted in the formation of the corresponding cyclic disilylimine, 1,4-bis(di-*tert*-butylmethylsilyl)- 2,3,5,6-tetraethyl-7-(2,6-dimethylphenylimino)-1,4 disilabicyclo[2.2.1]hepta-2,5-diene (**5**), which was isolated as pale yellow crystals in 59% yield (Scheme 2). *tert*-Butylisocyanide was also reacted with **1** under irradiation, and an NMR analysis of the photolysate showed the formation of the corresponding disilylimine derivative. However, because

SCHEME 2

of its instability the product was not isolated in a pure form.

Disilylimine **5** was fully characterized by IR and NMR spectroscopy. The ¹³C NMR chemical shift of the imine carbon for **5** (213.6 ppm) is shifted downfield from those of normal aliphatic imines (165–170 ppm) [9] and is quite similar to those of three-membered ring disilylimine, disilacyclopropanimine (214.0 ppm) [10] and the six-membered ring compound, pentasilacyclohexanimine (215.9 ppm) [11]. In the IR spectrum, the $C=N$ stretching frequency for **5** (1639 cm⁻¹) was observed at a higher wave number compared to those of reported cyclic disilylimines (1540–1580 cm−1) [10–12].

With the electropositive silyl groups on C atom and the electronegative aryl group on N atom of the $C=N$ group in 5, a small inversion barrier would be expected due to electronic reasons [13]. The activation parameters for the syn–anti isomerization of *N*-alkyl and *N*-fluoroalkylimines of hexafluoroacetone have been reported to show relatively low barriers to inversion (e.g., $\Delta G_{298}^{\ddagger} = 18.5 \pm 0.2$ kcal mol⁻¹, $ΔH[‡] = 19.2 ± 0.7$ kcal mol⁻¹, and $ΔS[‡] = 1.9 ±$ 1.9 cal mol−1K−¹ for (CF3)2C = N*ⁱ* Pr), which has been explained in terms of steric rather than the electronic effect [13]. Indeed, the H NMR spectrum of

SCHEME 3

5 in toluene- d_8 at 298 K does show a sharp signal for the methyl groups (0.26 ppm) of the *^t* Bu2MeSi groups because of rapid inversion at room temperature. Upon lowering the temperature, the $\rm{^1H}$ signals of the methyl protons in the *^t* Bu2MeSi groups broadened and split into two singlets (0.04 and 0.38 ppm) at 238 K. The temperature-dependent change of the ${}^{1}H$ signals results from the inversion of the 2,6-dimethylphenyl group on the imino nitrogen atom. From the Arrhenius and Eyring plots, the values of the free energy of the activation at coalescence temperature T_c ($\Delta G_{250} = 11.9 \pm 0.1$ kcal mol⁻¹), *E_a* = 14.2 ± 1.8 kcal mol⁻¹, $\Delta H^{\ddagger} = 13.7 \pm 1.8$ kcal mol⁻¹, and $\Delta S^{\ddagger} = 7.3 \pm 6.8$ cal mol⁻¹ K⁻¹ for the inversion can be estimated. This relatively low flipping barrier might be caused by the contribution of a linear transition state **5**', which is stabilized by delocalization of a lone pair on the imino nitrogen atom over the aromatic ring (Scheme 3).

The molecular structure of **5**, which is shown in Fig. 1, was determined by X-ray crystallographic analysis. Selected bond lengths and bond angles of **5** are given in Table 1. The C1–N1 bond length $(1.269(2)$ A) is close to those of normal imines and disilylimines [11,12]. The Si1–C1 and Si2–C1 bond lengths $(1.9647(17)$ and $1.9353(19)$ Å) in **5** are somewhat elongated compared with those of other Si-C bonds $(Si1-C2 (1.9196(19) \text{ A}), Si1-C5 (1.9153(19))$ A), Si2–C3 (1.9052(18) A), Si2–C4 (1.9018(19) A)) attached to $C=C$ bonds. The Si1–C1–Si2 bond angle $(93.75(8)°)$ is highly distorted from the normal sp² bond angle, 120◦ , and close to that reported for the cyclic disilyl ketone **2** (93.26(7)◦) [7].

Earlier papers by West et al. have described the isolation of trapping products believed to arise from hexamethyl-1,4-disilabenzene, including several

FIGURE 1 ORTEP drawing of **5** (30% thermal ellipsoids). Hydrogen atoms are omitted for clarity.

1,4-disilabarrelenes, by reaction with acetylenes [5]. Therefore, it is quite interesting to study the reactivity of **1** toward acetylenes. Thus, we examined the photolysis of **1** in the presence of phenylacetylene. Upon irradiation of a phenylacetylene solution of **1** in a sealed NMR tube with light of wavelength λ > 320 nm, the yellow color of 1 completely disappeared within 20 min. After removal of the solvent, 1,4-bis(di-*tert*-butylmethylsilyl)-2,3,5,6-tetraethyl-1- (2-phenylethynyl)-1,4-disilacyclohexa-2,5-diene **6** was unexpectedly obtained as colorless crystals in 92% yield (Scheme 4). No evidence for the formation of the corresponding 1,4-disilabarrelene derivative was found in this reaction.

All NMR spectra of **6** were in complete accord with its asymmetrical structure. In the ²⁹Si NMR spectrum of **6**, the skeletal Si atoms in **6** are characteristically shifted upfield, appearing at −62.0 $(Si-H)$ and -54.5 ($Si-C\equiv C$) ppm. Furthermore, we carried out an X-ray crystallographic analysis of **6** and confirmed that this compound has the cis configuration. An ORTEP drawing of **6** is shown in Fig. 2, together with selected bond lengths and angles (Table 2). The central disilacyclohexadiene ring

TABLE 1 Selected Bond Lengths (\AA) and Bond Angles (deg) of **5**

| 1.269(2) | $Si1-Si3$ | 2.4525(7) |
|-------------|------------------|---------------------------------------|
| 2.4129(7) | $Si1 - C1$ | 1.9647 (17) |
| 1.9353 (19) | $Si1-C2$ | 1.9196 (19) |
| 1.9153 (19) | $Si2-C3$ | 1.9052 (18) |
| 1.9018(19) | $C2-C3$ | 1.357(3) |
| 1.360(3) | | |
| | | |
| 142.96 (14) | $Si1 - C1 - Si2$ | 93.75(8) |
| 131.18(6) | $Si2-C1-N1$ | 123.16 (13) |
| 126.83 (15) | $C1-Si2-Si4$ | 118.25(6) |
| | | Bond Lengths (Å) Bond Angles (deg) |

SCHEME 4

FIGURE 2 ORTEP drawing of **6** (30% thermal ellipsoids). Hydrogen atoms are omitted for clarity.

of **6** has a boat conformation with a dihedral angle of 172.6◦ . The Si1–Si3 bond length (2.4197(6) A) of 6 is slightly shortened compared with that of **5** (2.4525(7) \AA) due to the lack of the bulky 2,6dimethylphenyl group, whereas the Si2–Si4 bond length $(2.4152(15)$ Å) remains essentially unchanged relative to that of $\overline{5}$ (2.4129(7) \check{A}).

The formation of **5** and **6** clearly shows the formation of the intermediate biradical species **8** by the photolytic cleavage of the strained central $Si-Si$ bond in **1**. The resulting **8** then undergoes a trapping

TABLE 2 Selected Bond Lengths (\AA) and Bond Angles (deg) of **6**

| 1.8527(19) | $Si1-Si3$ | 2.4197(6) | | |
|-------------------------|-------------|------------------|--|--|
| 2.4152(15) | $Si1 - C1$ | 1.8741(17) | | |
| 1.8689(17) | $Si2-C2$ | 1.8932 (17) | | |
| 1.8946 (18) | $C1-C2$ | 1.357(2) | | |
| 1.349(3) | $C14-C15$ | 1.208(3) | | |
| Bond Angles (deg) | | | | |
| 112.29 (8) 108.58(6) | $C2-Si2-C3$ | 111.84(8) | | |
| | | Bond Lengths (Å) | | |

reaction with isocyanide to produce the disilylimine **5**. In contrast, the formation of **6** can be explained by the reaction of **8** with phenylacetylene to give the vinyl radical **9**, which subsequently undergoes an intramolecular migration of the H atom in **9** to form the final product **6** (Scheme 5). The formation of **6** is quite different from the results reported in the earlier papers by West et al., which produced 1,4-disilabarrelene derivatives [5]. The formation of 1,4-disilabarrelene is unfavorable in the present case because of the steric factor, which prevents $Si-C$ bond formation in the intermediate **9** as a result of the steric bulkiness of the SiMe^{*t*}Bu₂ groups.

EXPERIMENTAL

General Procedures

All experiments were performed using high-vacuum line techniques or in an argon atmosphere of MBRAUN MB 150B-G glove box. All solvents were predried over sodium benzophenone ketyl

SCHEME 5

and finally dried and degassed over potassium mirror in vacuum prior to use. NMR spectra were recorded on a Bruker AC-300FT NMR spectrometer (1 H NMR at 300.1 MHz; 13 C NMR at 75.5 MHz; 29Si NMR at 59.6 MHz). Infrared spectrum was obtained on a JASCO FT/IR-410 spectrophotometer. UV-spectra were recorded on a Shimadzu UV-3150 UV–vis spectrophotometer. The silyl-substituted 1,4-disila(Dewar-benzene) **1**, 1,4 bis(di-*tert*-butylmethylsilyl)-2,3,5,6-tetraethyl-1,4 disilabicyclo [2.2.0] hexa-2,5-diene, was prepared by the reaction of 1,4-*anti*-bis(di-*tert*-butylmethylsilyl)- 1,4-dichloro-2,3,5,6-tetraethyl-1,4-disilacyclohexa-2,5-diene with potassium graphite [7].

*Synthesis of 1,4-Disilabicyclo- [2.2.1]hepta-2,5-diene (***5***)*

A THF (2 mL) solution of **1** (100 mg, 0.187 mmol) and 2,6-dimethylphenylisocyanide (24 mg, 0.183 mmol) in a glass tube was irradiated with a high-pressure Hg lamp (400 W, λ > 320 nm) for 24 h. After removal of the solvent in vacuo, the resulting residue was washed with pentane to give **5** (72 mg, 59%), which was obtained as pale yellow crystals. **5**: mp 171–172[∘]C; ¹H NMR (C₆D₆, 298 K, δ) 0.26 (s, 6H), 1.05 (t, *J* = 7.5 Hz, 12H), 1.13 (t, 36H), 2.08 (s, 6H), 2.53 (dq, *J* = 13.3 Hz, *J* = 7.5 Hz, 4H), 2.83 (dq, *J* = 13.3 Hz, *J* = 7.5 Hz, 4H), 6.77–6.91 (m, 3H); ¹³C NMR (C_6D_6 , 298 K, δ) –3.9, 16.6, 19.2, 21.0, 26.3, 30.3, 122.7, 125.6, 128.6, 151.7, 161.6, 213.6 (C=N); ²⁹Si NMR (C₆D₆, 298 K, δ) -36.4, 8.7. IR (KBr): $v(C=N)$ 1639 cm⁻¹. UV–vis (hexane) λ_{max} (nm) (ε) 334 (4000); Anal. Calcd for $C_{39}H_{71}NSi_4$ C, 70.30; H, 10.74; N, 2.10. Found: C, 69.41; H, 10.69; N, 1.93; HRMS: calcd for $C_{39}H_{71}NSi_4$: 665.4664; found: 665.4666.

*Synthesis of 7-(2-Phenylethynyl)-1,4-disilahexa-2,5-diene (***6***)*

A phenylacetylene (1.0 mL) solution of **1** (50 mg, 0.094 mmol) in a sealed glass tube was irradiated with a high-pressure Hg lamp (400 W, λ > 320 nm) for 4 h. After removal of the solvent, the residue was recrystallized from carbon tetrachloride/hexane to give **6** (55 mg, 92%) as colorless crystals. **6**: mp 164–166°C (dec); ¹H NMR (C₆D₆, 298 K, δ) 0.20 (s, 3H), 0.27 (s, 3H), 1.16 (s, 18H), 1.24 (t, *J* = 7.2 Hz, 6H), 1.29 (s, 18H), 1.40 (t, *J* = 7.5 Hz, 6H), 2.23 (dq, *J* = 7.5, 13.4 Hz, 2H), 2.56 (dq, *J* = 7.2, 13.4 Hz, 2H), 2.68–2.84 (m, 4H), 4.96 (s, 1H), 6.93– 6.99 (m, 3H), 7.43–7.45 (m, 2H); ¹³C NMR (C_6D_6 , 298 K, δ) −5.9, −5.8, 15.2, 16.0, 21.1, 21.8, 27.3, 27.6, 29.9, 30.3, 95.8, 109.1, 124.4, 128.6, 129.3, 131.6,

153.3, 154.1; 29Si NMR (C6D6, 298 K, δ) −62.0 (*Si* H), −54.5 (*Si* − C≡C), 2.1 (*Si* Me^{*r*}Bu₂), 4.0 (*Si* Me^{*r*}Bu₂); Anal. Calcd for $C_{38}H_{68}Si_4$ C, 71.62; H, 10.75. Found: C, 71.52; H, 11.01.

X-Ray Crystallographic Analyses of Compounds **5** *and* **6**

Pale yellow cubic single crystals of **5** were grown by the slow evaporation of its saturated hexane solution. Colorless single crystals of **6** were grown from the saturated solution in carbon tetrachloride and hexane. The intensity data were collected at 150 K for **5** and 120 K for **6** on a Mac Science DIP2030 image plat diffractometer with a rotating anode (50 kV, 90 mA) employing graphite-monochromatized Mo Kα radiation ($\lambda = 0.71071$ Å). The structures were solved by direct methods (SIR97) [14] and refined by full-matrix least-squares procedures on *F*² for all reflections (SHELX-97) [15]. Crystal data for **5**: formula $C_{39}H_{71}NSi_4$, $MW = 666.33$, monoclinic, space group $P2_1/c$, $a = 12.6950(6)$, $b = 20.8100(5)$, $c = 16.3160(8)$ Å, $\beta = 106.856(2)°$, $V = 4125.2(3)$ Å³, $Z = 4$, $D_{\text{caled}} = 1.073$ g cm⁻³, $\mu = 0.170$ mm⁻¹; R_1 $(I > 2\sigma(I)) = 0.0477$, wR_2 (all data) = 0.1354, $GOF = 1.024$ for 9890 reflections and 398 parameters. Crystal data for 6: formula $C_{38}H_{68}Si_4$, MW = 637.28, triclinic, space group *P*1, *a* = 10.3930(4), $b = 13.7580(5)$, $c = 15.4480(3)$ Å, $\alpha = 110.5710(2)$, $\beta = 100.6110(2), \quad \gamma = 92.6310(2)°, \quad V = 2017.92(11)$ \AA^3 , *Z* = 2, *D*_{calcd} = 1.049 g cm⁻³, μ = 0.170 mm⁻¹; *R*₁ $(I > 2 \sigma(I)) = 0.0437$, wR_2 (all data) = 0.1179, GOF = 1.059 for 7013 reflections, 404 parameters and 1 restraint. CCDC no. 659376 for **5** and CCDC no. 659377 for **6** contain the supplementary crystallographic data for this paper. These data can be obtained free of charge via the Cambridge Crystallographic Data Centre, 12 Union Road, Cambridge CB21EZ, UK (fax: (+44)1223-336-033; e-mail: deposit@ ccdc.cam.ac.uk).

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